

<b>INFORMATION DISCLOSURE CITATION</b> <small>(Use several sheets if necessary)</small>			Docket Number (Optional) <b>14945</b>		Application Number <b>09/965,565</b>		
			Applicant(s) <b>Yoshiyuki Nakamura</b>		Filing Date <b>Sept. 27, 2001</b>		Group Art Unit <b>210-213</b>
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
CZJ		4,942,576	7/17/90	Busack, et al.	714	719	
<b>RECEIVED</b>							
JAN 27 2004							
Technology Center 2100							
<b>FOREIGN PATENT DOCUMENTS</b>							
REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
CZJ	0 541 840 A1	5/19/93	EPO	→	→	✓	NO
↓	DE 195 10 990 A1	9/28/95	Germany	→	→	✓	YES
↓	JP 07198803	1/8/95	Japan	→	→	✓	NO
<b>OTHER DOCUMENTS</b> <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>							
Patent Abstract of Japan, Publication No. 07198803, dated 1/8/95							
<i>Moved to above</i>							
<b>EXAMINER</b> <i>Christina J.</i>			<b>DATE CONSIDERED</b> <i>5/12/04</i>				
<b>EXAMINER:</b> Initial if citation considered, whether or not citation is in conformance with MPEF Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							